

## pH and ORP Electrode Application Questionnaire v1.0

Application					
General					
Description:					_
□Industr		al?  Pilot	Plant?	☐ Field?	☐Laboratory?
Chemical – Does it contain		Harsh Acids:  Hydrochloric acid (33% HCL very aggressive)?  Hydrofluoric acid (will etch glass)?  Nitric acid (will attack Ryton)?			
		Harsh Alkalis:	<ul> <li>□ Caustic soda or similar</li> <li>□ Strong brine?</li> <li>□ Ions that precipitate potassium chloride?</li> <li>□ Bromides, iodides, cyanides, sulphides?</li> <li>□ Heavy metals, chlorates, mercaptans?</li> <li>□ Solvents?</li> <li>□ Fluorides?</li> </ul>		
Is your sample:		☐ Clean water? ☐ Sticky? ☐ Biological? ☐ Non-Aqueous?	☐ Dirty v ☐ Abrasi ☐ Brine? ☐ An em		☐ Very clean water? ☐ Viscous? slurry?
Physical: Is your mounting:					
A:  In Line		B: Submersion	(	: Insertion	D: Side Stream
	-	~~~~		<i>p</i> )	H 1
Likely pH Rar Please fill in:		Min			
Failure of Previous					
Electrodes due to:					
Other Comments:					
I		I			